

FIR-VUV Ellipsometry on $B_xGa_{1-x}As$ and GaN_yAs_{1-y}



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Motivation

- GaN_{1-y} and $B_xGa_{1-x}As$ differ fundamentally in their bonding properties, i. e., B-As is almost purely covalent whereas Ga-N bond has large ionic contribution
- Influence of ionicities on bandstructure and phonon properties
- $In_xGa_{1-x}N_yAs_{1-y}$ and $B_xGa_{1-x}InAs$ as new materials for 1.3-1.55 μm laser diodes and solar cells
- Effect of hydrogen on bandstructure of $In_xGa_{1-x}N_yAs_{1-y}$?

$B_xGa_{1-x}As$

- $a_0^{BAs} = 4.777 \text{ \AA} \rightarrow \Delta a/a = 16\%$
- Ionicity of the B-As bond: $f_i^{BAs} = 0.002$
- BAs-like phonon could not be detected using IR ellipsometry or IR transmission due to low ionicity of B-As-bond
- BAs-phonon is Raman-active
- Perturbation potential of B in GaAs mainly due to strain
- Weaker than perturbation potential of N in GaAs
- Small bowing parameters of all detected critical-point transitions (E_0 , E_1 , $E_1+\Delta_1$, E_0' , E_2 and E_1')
- $B_xGa_{1-x}As$ behaves like a „normal alloy“!

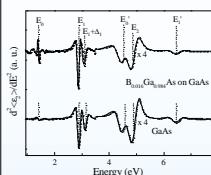
Conclusion

GaN_yAs_{1-y}

- $a_0^{p-GaN} = 4.52 \text{ \AA} \rightarrow \Delta a/a = 20\%$
- Ionicity of the Ga-N bond: $f_i^{GaN} = 0.500$
- GaN-like phonon is infrared-active (high ionicity of Ga-N-bond)
- Strong, shortranging perturbation potential of N in GaAs due to strain and the large ionicity of the Ga-N bond
- Drastic redshift of E_0 with increasing y
- Redshift can be neutralized by Hydrogen implantation
- Moderate shift of E_1 , $E_1+\Delta_1$, E_0' , E_2 and E_1' with $y \rightarrow$ perturbation of the band-structure concentrated on the Γ -point of the Brillouin zone
- GaN_{1-y} does not behave like a „normal alloy“!

Bandstructure of $B_xGa_{1-x}As$ and GaN_yAs_{1-y}

$B_xGa_{1-x}As$



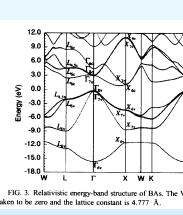
- Small blueshift of E_0 with x
- Redshift of the direct interband transitions E_1 , $E_1+\Delta_1$, E_0' , E_2 a. E_1' with increasing x

GaN_yAs_{1-y}

- Drastic redshift of E_0 with y
- Blueshift of the interband-transitions E_1 and $E_1+\Delta_1$ with y
- Small redshift of the critical points E_0' , E_2 and E_1' with y

Bas-bandstructure

[G. L. Hart and A. Zunger, Phys. Rev. B 62, 13522 (2000)]



- Small blueshift of E_0 and redshift of E_0' , E_2 , a. E_1' with x can be described by small bowing coefficients of $b \approx 0.7$, 1.6 , 1.4 , and 0.9 eV, respectively [3]

→ Influence of B on the $B_xGa_{1-x}As$ bandstructure is rather small

[J. R. Chalkowsky a. M. L. Cohen, Phys. Rev. B14, 556 (1976)]

FIG. 1. Band structure of GaAs reproduced from Ref. 4 showing the main interband critical points.

[3] G. Leibiger et al., Phys. Rev. B 67, 195205 (2003); [4] T. Martínez et al., Phys. Rev. B 60, R11245 (1999); [5] G. Leibiger et al., Appl. Phys. Lett. 77, 1650 (2000)

Ionicities of the bonds

Electronegativity

Electronegativity	
B	2.01 (2s ² 2p ¹) 0.853 Å
C	2.55 (2s ² 2p ²)
N	3.07 (2s ² 2p ³) 0.719 Å
Al	1.61 (3s ² 3p ¹)
Si	1.90 (3s ² 3p ²)
Ge	2.01 (3s ² 3p ²)
As	2.20 (3s ² 3p ³) 1.225 Å
In	1.78 (4s ² 4p ¹)
Sn	1.96 (4s ² 4p ²)
Sb	2.05 (4s ² 4p ³)

Tetrahedral radius

- Phillips/Van Vechten model: $E_g^2 = E_h^2 + C^2$ (E_g band gap, C ionic and E_h homopolar contribution to E_g) [7,8]

→ Ionicity of a bond: $f_i \equiv C^2/E_g^2$ [7,8]

B-As	Ga-As	Ga-N
$f_i = 0.002$	$f_i = 0.310$	$f_i = 0.500$

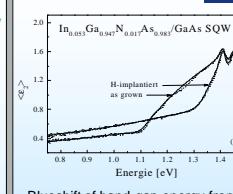
⑧ B-As bond is almost purely covalent, whereas the Ga-N bond has a large ionic contribution

[7] J. A. Van Vechten, Phys. Rev. B67, 195205 (2003); [8] J. C. Phillips, Bonds and Bands in Semiconductors, Academic Press, New York 1973.

Acknowledgement

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Hydrogen Implantation in $In_xGa_{1-x}N_yAs_{1-y}$

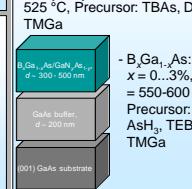


- Blueshift of band-gap energy from 1.109 eV (as grown) to 1.336 eV (H-impl.) measured with ellipsometry and PL → redshift due to nitrogen almost neutralized
- Thermal annealing at 300°C (red line in PL spectrum) → original band gap energy recovered due to outdiffusion of Hydrogen
- Explanation: α -H_n(N) complexes (see right); interruption of N-Ga-bond and saturation of both dangling bonds with Hydrogen
- (Sample: $In_{0.053}Ga_{0.947}N_{0.017}As_{0.983}/GaAs-SQW$, $d_{well}=10$ nm, ~20 nm GaAs-caplayer)

Samples

MOPVE (metalorganic vapor-phase epitaxy)

- GaN_{1-y} : $y = 0\dots 3.7\%$, $T_G = 525^\circ C$, Precursor: TBAs, DMHy, TMGa



- $B_xGa_{1-x}As$: $x = 0\dots 3\%$, $T_G = 550-600^\circ C$, Precursor: AsH₃, TEB, TMGa
- $In_xGa_{1-x}N_yAs_{1-y}$: $x = 0.053$, $y = 0.017$, $T_G = 550-600^\circ C$, Precursor: TMGa

Experiment

Ellipsometry: far- and mid-infrared range ($100 \text{ cm}^{-1} \leq \omega \leq 600 \text{ cm}^{-1}$) and near-infrared-VUV range ($0.75 \text{ eV} \leq E \leq 8 \text{ eV}$), $T = 300 \text{ K}$

- Raman: Dilor XY 800 in macroconfiguration; $\lambda_{ex} = 514.5 \text{ nm}$, $P_{ex} = 50 \text{ mW}$, $\lambda_{det} = 514.5 \text{ nm}$, $P_{det} = 50 \text{ mW}$

Photoluminescence (PL):

- $\lambda_{ex} = 514.5$, $T = 300 \text{ K}$

H-Implantation:

- Kaufmann-source, $E_{ion} = 300 \text{ eV}$, $T_{sample} = 300^\circ C$, dose = $4.4 \cdot 10^{17}$ Ions/cm²

Damped harmonic oscillators

Model Dielectric Function

Model Dielectric Function

$$\text{Polar phonons: } E^{(p)}(\mathbf{w}) = - \sum_{i,j} \frac{\omega_{i,j}^2}{\omega_{i,j}^2 - \mathbf{w}^2 - i\omega_{i,j}\gamma_{i,j}}$$

$$\text{here: no anharmonic interaction: } \gamma_{LO} = \gamma_{TO}$$

$$[F. Gerlach und B. Pötsch, J. Phys. C7, 2374 (1974); F. Gerlach, B. Pötsch und C. Ullrich, Phys. Rev. B34, 791 (1986)]$$

$$\text{Free carriers: } E^{(FC)}(\omega) = -\varepsilon - \frac{\omega_c^2}{\omega(\omega + i\gamma_p)}$$

$$\text{with } \omega_c = \sqrt{\frac{Ne^2}{\varepsilon_0 \cdot \varepsilon_m}}$$

$$[P. Drude, Wiss. Ann. 39, 481 (1890)]$$

$$\text{Valence electrons}[1,2]: \text{Interband transitions } E_0, E_1, E_1+\Delta_1, E_0', E_2, E_1'$$

$$E^{(0,1)}(E) = A_i E^{-1.5} (c_j^{-1} [2 - (1 + c_j)^{0.5} - (1 - c_j)^{0.5}]) \quad \text{with } c_j = (E + i\Gamma_j)/E_j$$

$$E_1, E_1+\Delta_1: E^{(1,1)}(E) = -A_i c_j^{-2} \ln(1 - c_j^2)$$

$$\text{plus: excitonic contributions to } E_1 \text{ and } E_1+\Delta_1 \text{ due to Lorentzian lineshapes}$$

$$E_0', E_2, E_1': \text{Damped harmonic oscillators}$$

$$[1] S. Adachi, Physical Properties of III-V Semiconductor Compounds (Wiley, New York 1992); [2] C. W. Higginbotham et al., Phys. Rev. B4, 821 (1976)]$$